

Fluorescence

Inscription(s)

Type IIa

# GEMOLOGICAL INSTITUTE

## **ELECTRONIC COPY**

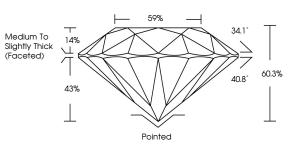
#### LABORATORY GROWN DIAMOND REPORT

March 14, 2024	
IGI Report Number	LG625444462
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	ROUND BRILLIANT
Measurements	9.72 - 9.74 X 5.87 MM
GRADING RESULTS	
Carat Weight	3.41 CARATS
Color Grade	G
Clarity Grade	VS 1
Cut Grade	IDEAL
ADDITIONAL GRADING INFORMA	TION
Polish	EXCELLENT
Symmetry	EXCELLENT

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth

process and may include post-growth treatment.

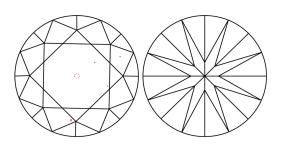
### PROPORTIONS



LABORATORY GROWN DIAMOND REPORT

LG625444462 Report verification at igi.org

#### **CLARITY CHARACTERISTICS**



#### **KEY TO SYMBOLS**

NONE

151 LG625444462

Red symbols indicate internal characteristics. Green symbols indicate external characteristics. LABORATORY GROWN DIAMOND REPORT

#### GRADING SCALES

#### CLARITY

IF	VVS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	l <sup>1-3</sup>
Internally	Very Very	Very	Slightly	Included
Flawless	Slightly Included	Slightly Included	Included	

#### COLOR

DEF	G	Н	I	J	Faint	Very Light	Light
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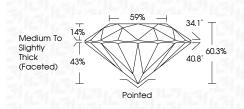


Sample Image Used

#### LABORATORY GROWN DIAMOND REPORT

# Manah 14 0004

March 14, 2024	
IGI Report Number	LG625444462
Description	LABORATORY GROWN DIAMOND
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Measurements	9.72 - 9.74 X 5.87 MM
GRADING RESULTS	
Carat Weight	3.41 CARATS
Color Grade	G
Clarity Grade	VS 1
Cut Grade	IDEAL



#### ADDITIONAL GRADING INFORMATION

Type IIa

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	任 <b>第1 LG62544446</b> 2
Comments: This Laboratory created by Chemical Vapor process and may include p	or Deposition (CVD) growth



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